



# Optimisation of the CLIC positron source

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### Outline

• Introduction

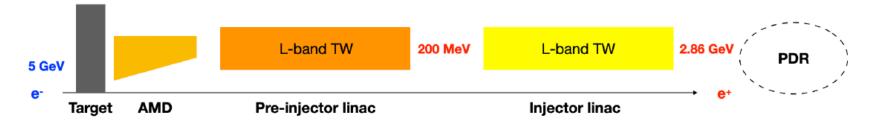
• Baseline option

• Alternative options

• Conclusions

### Introduction

• Schematic layout (baseline) of the CLIC positron source



- Merit functions to optimize
  - Maximum accepted positron yield by PDR
  - Peak energy deposition density (PEDD) < 35 J/g</li>
- Simulation
  - Electron gun & drive beam linac are not simulated
  - Primary electron drive beam simulated with Gaussian sampling
  - Target simulated with Geant4
  - Matching device (AMD) magnetic field obtained from Opera<sup>®</sup>
  - Pre-injector linac (capture linac) simulated with RF-Track
  - Injector linac simulated with Placet

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Accepted e<sup>+</sup> yield:  $\eta = \frac{N_{e^+}^{\text{PDR}}}{N_{e^-}^{\text{Primary}}}$ 

### Beam parameters

Primary e<sup>-</sup> beam parameters

Drive-beam based mode assumed

• Spot size is a free parameter

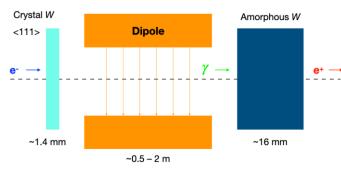
Electron beam parameter	Unit	$380{ m GeV}$	$3\mathrm{TeV}$
Beam energy	${\rm GeV}$	5	
Number of bunches per train		352	312
Bunch length $(RMS)$	$\mathrm{mm}$	1	
Energy spread (RMS)	%	0.1	
Emittance, $\epsilon_{x,y}^n$	$\mathrm{mm}{\cdot}\mathrm{mrad}$	80	

- Required e<sup>+</sup> beam parameters at PDR entrance
  - 20% safety margin is included in the bunch charge

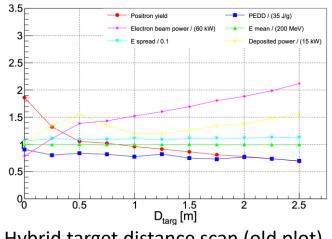
Positron beam parameter	Unit	$380{ m GeV}$	$3{ m TeV}$	
Beam energy	$\mathrm{GeV}$	2.	86	
Number of bunches per train		352	312	
Bunch population		$6.24 \times 10^9$	$4.44 \times 10^9$	
Bunch charge	nC	1.00	0.71	
PDR energy acceptance $(\pm)$	%	1.2		
PDR time window (total length)	$\mathrm{mm/c}$	20		

## Target

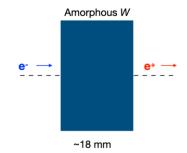
Previously, in the old baseline of the CDR and the PIP report, a hybrid target was proposed to reduce the PEDD. However, we found that the yield is also reduced significantly. Therefore, in our new baseline, the conventional target is assumed



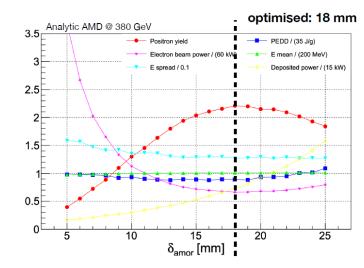
### Hybrid target option (old baseline)



Hybrid target distance scan (old plot)



#### Conventional target option (**new baseline**)

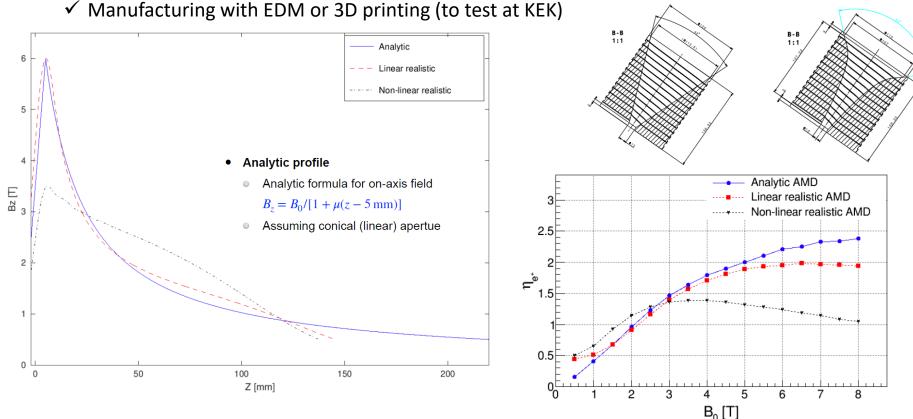


Conventional target thickness scan (old plot)

## Adiabatic matching device (AMD)

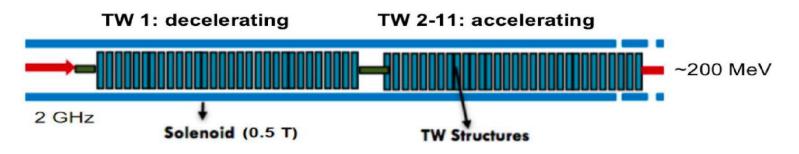
- Two main types of flux concentrator (FC) used as the AMD are studied
  - Linear aperture: higher peak field, much higher yield (baseline)
  - Non-linear aperture: lower power supply & voltage, lower yield

#### Designed by H. Bajas



Field map (peak field scaled to optimised value)

### Pre-injector linac



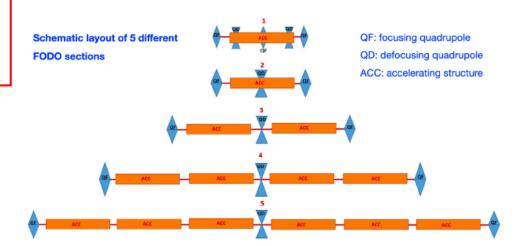
- CLIC L-band (similar with injector and booster linacs), 2 GHz travelling wave (TW) structures,  $2\pi/3$
- 1.5 m long, 20 mm iris radius aperture, 200 mm distance
- Number of structures: 1 dec. + 10 acc. (phases optimised for max. PDR accepted yield)
- To simplify the study, RF gradients are fixed at 20 MV/m, acc. structures have the same phase
- NC solenoid (up to ~200 MeV): 0.5 T
- It is also found that (if technically allowed)
  - ✓ Yield can be increased with shorter distance (between dec. and acc. structures)
  - ✓ Yield can be increased with higher NC solenoid field

## Injector linac

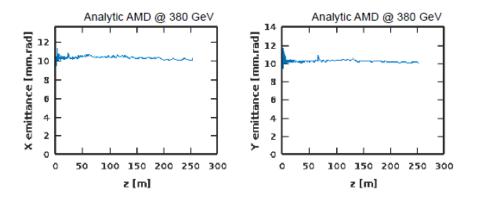
#### In optimisation

#### analytic

- $\Delta E = (2.86 \,\text{GeV} E_{\text{ref}}) \cdot \cos[\omega \cdot (t t_{\text{ref}})]$ Θ
- Reference particle with energy ~200 MeV Θ
- In final simulation
  - based on previous design by C. Bayar Θ
  - 5 different FODO sections Θ
  - 143 quadupoles (16 for matching) Θ
  - Good matching & no loss in yield Θ



Analytic AMD @ 380 GeV



Normalised emittances (RMS) vs Z position

size [cm] 0.3 0.8 0.6 Y beam 0.4 0.2 0 50 100 150 200 250 300 Ð 50 100 150 200 250 300 z [m] z [m]

1.2

Beam sizes (RMS) vs Z position

#### The analytic formula is used, as it was found to have consistent final results with Placet simulation $\checkmark$

1.2

1

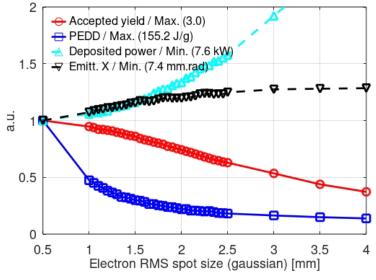
Analytic AMD @ 380 GeV

## Baseline final results

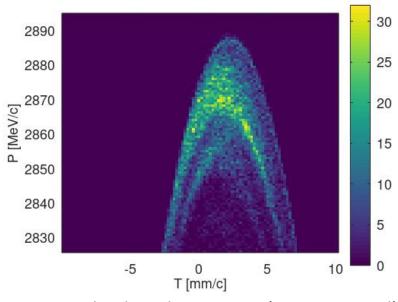
### • Optimisation results

Positron beam parameter	Unit	$380{ m GeV}$	$3{\rm TeV}$
Optimised electron beam spot size, $\sigma_{x,y}$	mm	2.10	1.40
Electron bunch charge required	nC	0.47	0.28
Electron beam power required	kW	39.3	20.3
Positron bunch charge required at PDR entrance	nC	1.00	0.71
Positron yield accepted by PDR		2.12	2.58
Normalised total deposited power in target	kW	10.6	5.5
Normalised PEDD in target	J/g	32.0	31.6

#### PEDD & power normalised. BC (e+) = 1.0 nC



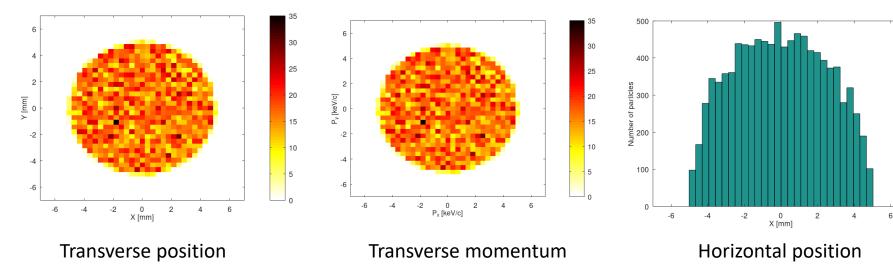
Primary e<sup>-</sup> beam spot size scan (380 GeV)



Longitudinal e<sup>+</sup> phase space (PDR accepted)

## Alternative option 1: uniform beam

Primary e<sup>-</sup> beam with uniform transverse distribution



### Optimisation results

<u> </u>				
7	Positron beam parameter	$\operatorname{Unit}$	$380{ m GeV}$	$3{ m TeV}$
	Optimised electron beam radius, $R_{x,y}$	$\mathbf{m}\mathbf{m}$	2.90	2.10
	Electron bunch charge required	$\mathbf{nC}$	0.39	0.26
P	Electron beam power required	kW	32.5	19.0
	Positron bunch charge required at PDR entrance	nC	1.00	0.71
	Positron yield accepted by PDR		2.57	2.74
P	Normalised total deposited power in target	kW	8.7	5.1
4	Normalised PEDD in target	J/g	31.5	31.5

2

1.5

0.5

0.5

a.u.

PEDD & power normalised. BC (e+) = 1.0 nC

- 6464666666

2.5

2

Electron beam radius (uniform) [mm] Beam radius scan

3

3.5

4

Accepted yield / Max. (3.0)

- Emitt. X / Min. (7.2 mm.rad)

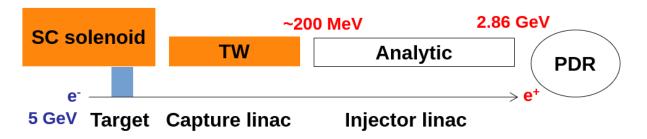
1.5

📥 Deposited power / Min. (7.4 kW)

PEDD / Max. (244.7 J/g)

### Alternative option 2: SC AMD

• Schematic layout with a SC solenoid as AMD (idea from FCC-ee study)



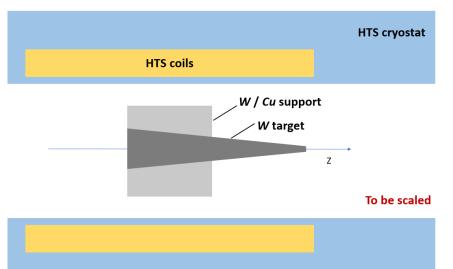
- Optimisation results of using the FCC-ee HTS AMD for CLIC
  - Reoptimisation of the HTS field (analytic) shows very little improvement

Positron beam parameter	Unit	$380{ m GeV}$	$3{ m TeV}$
Optimised electron beam spot size	$\mathbf{m}\mathbf{m}$	1.85	1.20
Optimised target exit face position	$\mathbf{m}\mathbf{m}$	75	62
Electron bunch charge required	nC	0.38	0.22
Electron beam power required	kW	32.1	16.2
Positron bunch charge required at PDR entrance	nC	1.00	0.71
Positron yield accepted by PDR		2.60	3.22
Normalised total deposited power in target	kW	8.6	4.4
Normalised PEDD in target	J/g	32.5	31.2

## Alternative option 3: tapered target + SC AMD

### Tapered target (idea from FCC-ee study)

- Target to be put inside a SC AMD
- FCC-ee HTS AMD field is used



• Optimisation results

Parameter	Unit	$380{ m GeV}$	$3{ m TeV}$
Tungsten or copper support length	$\mathbf{m}\mathbf{m}$	15	
Optimised target length	$\mathbf{m}\mathbf{m}$	27.6	26.1
Optimised target radius at the entrance	$\mathbf{m}\mathbf{m}$	5.4	3.5
Optimised target radius at the exit	$\mathbf{m}\mathbf{m}$	0.55	0.33
Optimised electron beam spot size	$\mathbf{m}\mathbf{m}$	1.80	0.95
Optimised target exit face position	$\mathbf{m}\mathbf{m}$	84	63
Electron bunch charge required	nC	0.32	0.15
Electron beam power required	kW	30.1	12.5
Positron bunch charge required at PDR entrance	nC	1.00	0.71
Positron yield accepted by PDR		3.12	4.84
Normalised total deposited power in target	kW	6.6	2.6
Normalised PEDD in target	J/g	31.7	32.3

## Alternative option 4: Uniform beam + tapered target + SC AMD

• Optimisation results (uniform beam + tapered target + FCC-ee HTS AMD)

Parameter	Unit	$380{ m GeV}$	$3{ m TeV}$
Tungsten or copper support length	$\mathbf{m}\mathbf{m}$	15	
Optimised target length	$\mathbf{m}\mathbf{m}$	30.5	30.2
Optimised target radius at the entrance	$\mathbf{m}\mathbf{m}$	4.5	3.1
Optimised target radius at the exit	$\mathbf{m}\mathbf{m}$	0.54	0.32
Optimised electron beam radius	$\mathbf{m}\mathbf{m}$	2.30	1.40
Optimised target exit face position	$\mathbf{m}\mathbf{m}$	94.3	64
Electron bunch charge required	nC	0.24	0.12
Electron beam power required	kW	22.7	10.7
Positron bunch charge required at PDR entrance	nC	1.00	0.71
Positron yield accepted by PDR		4.20	5.72
Normalised total deposited power in target	kW	6.6	2.9
Normalised PEDD in target	J/g	32.4	32.9

### Alternative option 5: lower beam energy

 Lower e<sup>-</sup> drive beam energy requires shorter drive beam linac, but larger bunch charge

<ul> <li>Optimisation results</li> </ul>	Parameter		Val	ues
	Electron beam energy	$\mathrm{GeV}$	1	3
	Optimised electron beam spot size, $\sigma_{x,y}$	$\mathbf{m}\mathbf{m}$	2.30	2.15
	Optimised target thickness	$\mathbf{m}\mathbf{m}$	13	16
Electron bunch charge required Electron beam power required		nC	2.17	0.78
		kW	35.3	38.1
380 GeV	Positron bunch charge required at PDR entrance	nC	1.00	1.00
	Positron yield accepted by PDR		0.46	1.29
	Normalised total deposited power in target	kW	9.5	9.7
	Normalised PEDD in target	J/g	32.3	32.4

Parameter	Unit	Val	ues	
Electron beam energy	$\mathrm{GeV}$	1	3	
Optimised electron beam spot size, $\sigma_{x,y}$	$\mathbf{m}\mathbf{m}$	1.45	1.35	
Optimised target thickness	$\mathbf{m}\mathbf{m}$	13	16	
Electron bunch charge required	nC	1.20	0.43	
Electron beam power required	kW	17.2	19.3	3 TeV
Positron bunch charge required at PDR entrance	nC	0.71	0.71	5 180
Positron yield accepted by PDR		0.59	1.64	
Normalised total deposited power in target	kW	4.6	4.9	-
Normalised PEDD in target	J/g	31.8	32.6	

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### Comparison of results

### • Comparison of all options

- **UB**: using **uniform** e- drive beam, otherwise same with baseline
- HTS: using FCC-ee HTS AMD, otherwise same with baseline
- TT: using tapered target + HTS AMD, otherwise same with baseline
- UB-TT: using uniform beam + tapered target + HTS AMD, otherwise same with baseline
- LE: using lower e- drive beam energy, otherwise same with baseline

	Parameter	Unit	Baseline	UB	HTS	ΤT	UB-TT	LE
	Electron beam energy	$\mathrm{GeV}$	5	5	5	5	5	3
	Electron beam spot size or radius	$\mathbf{m}\mathbf{m}$	2.10	2.90	1.85	1.80	2.30	2.15
	Electron bunch charge required	nC	0.47	0.39	0.38	0.32	0.24	0.78
200 Call	Electron beam power required	kW	39.3	32.5	32.1	30.1	22.7	38.1
380 GeV	Normalised PEDD in target	J/g	32.0	31.5	32.5	31.7	32.4	32.4
	Positron bunch charge required at PDR entrance	nC	1.00	1.00	1.00	1.00	1.00	1.00
	Positron yield accepted by PDR	$e^+/e^-$	2.12	2.57	2.60	3.12	4.20	1.29
	Demonster	II:4	Deceliere	UD	UTC	mπ		LE
	Parameter	Unit	Baseline	UB	HTS	TT	UB-TT	LE
	Electron beam energy	$\mathrm{GeV}$	5	5	5	5	5	1
	Electron beam spot size or radius	$\mathbf{m}\mathbf{m}$	1.40	2.10	1.20	0.95	1.40	1.45
	Electron bunch charge required	nC	0.28	0.26	0.22	0.15	0.12	1.20
3 TeV	Electron beam power required	kW	20.3	19.0	16.2	12.5	10.7	17.2
	Normalised PEDD in target	J/g	31.6	31.5	31.2	32.3	32.9	31.8
	Positron bunch charge required at PDR entrance	nC	0.71	0.71	0.71	0.71	0.71	0.71
	Positron yield accepted by PDR	$e^+/e^-$	2.58	2.74	3.22	4.84	5.72	0.59

### Conclusions

- Though yields were likely over-estimated previously, a comparison is made
  - AMD aperture seems not simulated in previous studies (not tapered): ~25% yield loss
  - PDR energy acceptance seems too large in previous studies (1.2% rms): ~15% yield loss
  - Compared with the old CDR baseline published in 2012 (η = 0.4 @ 3 TeV), the new baseline yield (2.1 @ 380 GeV, 2.6 @ 3 TeV) is increased by factors of 6.5
  - Compared with the old PIP baseline published in 2018 (η = 1.0 @ 3 TeV), the new baseline yield is increased by a factor of 2.6
  - Compared with a report by Y. Han published in 2019 (1.3 @ 380 GeV, 1.9 @ 3 TeV), the yields are increased by 63% and 33%
- Alternative options (though a bit challenging), compared with the new baseline, at 380 GeV (3 TeV), can further improve the yield:
  - Yield is increased by 21% (6%) if using uniform e- drive beam
  - Yield is increased by 23% (25%) if using FCC-ee HTS AMD
  - Yield is increased by 47% (88%) if using tapered target + HTS AMD
  - Yield is increased by 98% (122%) if using uniform beam + tapered target + HTS AMD
  - 0.8 (1.2) nC e- bunch is required if energy reduced to 3 (1) GeV
- Next steps
  - Try to design a lattice for the uniform drive beam (quite challenging)

### Acknowledgement

- Thanks very much for your attention!
- We thank H. Bajas for his efforts in designing the flux concentrator for the baseline CLIC AMD when he worked at CERN.
- We also thank J. Kosse, B. Auchmann, M. Duda, et al. from PSI for providing the HTS solenoid field map designed for the FCC-ee AMD.

# Backup